

AMENDMENTS TO THE SPECIFICATION

Please replace the Title with the following:

-- FABRICATION METHOD OF A LIQUID CRYSTAL DISPLY DEVICE USING A
PRINTING METHOD --

Please amend paragraph **0001** of the specification as follows:

[0001] The invention relates to a fabrication method of a liquid crystal display (LCD) device, and more particularly, to a fabrication method of an LCD device including a printing method for a gate or ~~date~~ data line using pattern having a wider effective line width.

Please amend paragraph **0046** bridging pages 9 and 10 of the specification as follows:

[0046] As shown in Figure 3E, the N+ layer 304 and the amorphous silicon layer 303 on the residual regions where the resist is not deposited are etched and removed by using the photoresist 306 as a mask. Then, the photoresist 306 is removed. Next, a conductive layer 305 for forming a source/drain electrode is deposited on the resulting material, photoresist 311 is deposited, a mask is applied, an exposure is performed, and a source/drain electrode pattern is thereby formed. As a result, the photoresist pattern 311 for forming a source/drain electrode is complete. This mask is the only mask used

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in the invention. [~~PLEASE VERIFY. THERE APPEARS TO BE TWO MASKS 306 AND
311.~~]